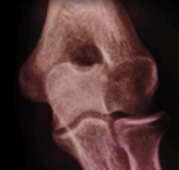
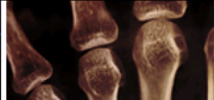




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Research Article

Collimated Magnetron Sputter Deposition for Mirror Coatings

Anette Vickery,¹ Carsten P. Jensen,² Finn E. Christensen,² Mads Peter Steenstrup,³ and Troels Schönfeldt³

¹Nano-Science Center, University of Copenhagen, The H. C. Ørsted Institute, Universitetsparken 5, 2100 Copenhagen, Denmark

²Danish National Space Center, Juliane Maries Vej 30, 2100 Copenhagen, Denmark

³Niels Bohr Institute, University of Copenhagen, The H. C. Ørsted Institute, Universitetsparken 5, 2100 Copenhagen, Denmark

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Abstract

At the Danish National Space Center (DNSC), a planar magnetron sputtering chamber has been established as a research and production coating facility for curved X-ray mirrors for hard X-ray optics for astronomical X-ray telescopes. In the following, we present experimental evidence that a collimation of the sputtered particles is an efficient way to suppress the interfacial roughness of the produced multilayer. We present two different types of collimation optimized for the production of low roughness curved mirrors and flat mirrors, respectively.

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